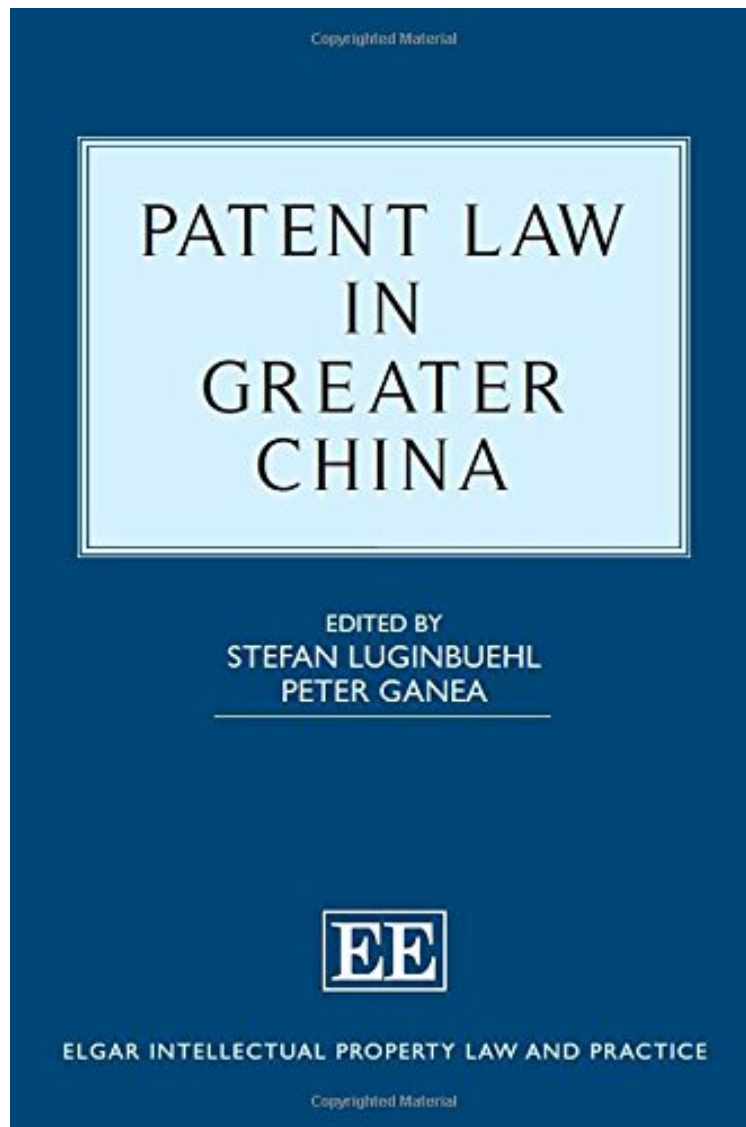


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Taylor MBE and Elizabeth Taylor of Richmond Green Chambers With the Peoples Republic of China well on its way to becoming the worlds largest economy, it has become well-nigh imperative for intellectual property lawyers and scholars -- particularly patent practitioners -- to increase and enhance their understanding of intellectual property issues emanating from China. Hitherto, accessing the necessary research and information on this subject has been no easy task, which is why Patent Law in Greater China published by Edward Elgar, has emerged as such an important and useful book. Here in a single volume, you have at your fingertips, a wealth of research, analysis and practical down-to-earth advice, not to mention a thorough survey of patent law in Greater China, which encompasses the PRC (Peoples Republic of China), Hong Kong, Macau and Taiwan. The book contains the specialist insights provided by no less than twenty-five experts in this field (including academics and judges) from a variety of top law firms, government bodies and universities worldwide, including for example, Harvard, Edinburgh and Peking. All contributors have China-related experience. The book therefore puts forward a variety of opinion, as well as information, which is well worth noting. The editors point out that the Peoples Republic of China has developed a fully fledged and functioning patent system only within the last thirty years. Even though not all these established practices are in the very interest of users, admit the editors, one should not underestimate the positive effects of such enhanced transparency and predictability of administrative and judicial decision making on both Chinese and foreign parties. In providing an overview of Chinese patent law and practice, the book introduces the reader to the political and legal background of key patent-related issues. In particular, there are analyses of patent law in three specific areas: employee inventions, biotechnological and pharmaceutical inventions and software inventions. Part C on patent application and procedure -- including applications -- offers much useful practical advice. Also intriguing is the section on utility model and design protection. These issues and literally hundreds of others are covered with thoroughness and outstanding clarity throughout the book, which also functions as a uniquely comprehensive research resource, with its bibliography of books and articles, webpages and periodicals. There are useful tables of cases and of legislation and -- also very handy -- a lengthy list of abbreviations. One cannot help remarking that intellectual property specialists will find this book a revelation. The wide-ranging perspective it provides on Chinese patent law is remarkable and certainly no patent practitioner should be without it. The publication date is cited as 2014.

'Patent Law in Greater China provides some of the most comprehensive, up-to-date and contextualized analyses of Chinese patent law. Featuring expert contributors with diverse backgrounds and deep inside knowledge, this edited volume strikes a good balance between scholarly analysis and practical tips. The book should be on the desk of everybody who handles patent-related matters in Greater China.' - Peter K. Yu, Drake University Law School, US 'Chinese intellectual property law has been one of the fields in which it has been most difficult to obtain an accurate, reliable and intelligible perspective. The achievement in putting together Patent Law in Greater China is therefore all the more laudable. Chapters from practitioners, administrators, academics and the business world give this work a degree of relevance and immediacy and show how the complex and initially puzzling interplay of law and practice in China and the economies within her orbit can be depicted and understood.' - Jeremy Phillips, Queen Mary Intellectual Property Research Institute, UK 'Drs Luginbhl and Ganea have put together an impressive and thorough survey of patent law in the PRC, Hong Kong, Macau and Taiwan. The book covers policy making aspects, patentability requirements (with specific chapters on biotechnological, chemical, pharmaceutical and software-related inventions), rights and exceptions, employee inventions, rights in designs and utility models, but also patent prosecution (domestic and PCT), infringement, and the interface with competition law. This timely book will be useful for both practitioners and scholars.' - Daniel Gervais, Vanderbilt University Law School and Editor in Chief, Journal of World Intellectual Property This book provides a comprehensive introduction to patent policy, law and practice in Greater China and will be a go-to book for patent practitioners who have client interests in that region. Features: - Introduction to Chinese patent policy. - Detailed coverage of technology transfer and substantive patent law in China, including prerequisites for protection, exceptions and limitations. - Practical analysis of patent law relating to 3 specific fields of invention: employee inventions, biotechnological and pharmaceutical inventions, and software inventions. - Overview of the patent application and examination procedure, with a particular view on PCT applications. - Insight into specific characteristics of enforcement mechanisms and jurisprudence in China, including the dual enforcement system, claim interpretation, infringement types, and invalidity procedures. - Invaluable section on the relationship between patent and antitrust law, including practical realities in the sphere of anticompetitive licensing. - Overviews of the patent systems of Chinese Taipei, Hong Kong SAR and Macau SAR - Edited by two leading patent experts, and written by a team of experienced practitioners from China and from Europe, offering insight rarely brought together in a single place. This book will be an indispensable reference work for lawyers, patent attorneys and other practitioners interested in learning whether and how to protect patents in China. Contributors: C. Bailey, Y. Bu, J. Cao, W. Chen, D. Clark, G. Cui, C. Czychowski, M. Deng, P. Ganea, H. Goddar, N. Heide, S.-H. Lee, J. Li, Y. Li, K.-C. Liu, S. Luginbuehl, Q. Ma, T. Mak, J.B. Nordemann, T. Pattloch, O. Pfaffenzeller, B. Roth, C.D. Simes, L. Wang, B. Weibel

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